
Diffusion Induced Modulation of Co-Propagating (Acousto-Optic) Waves In Transversely Magnetized Semiconductor Plasmas Applied to n-InSb at 77K

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ABSTRACT

The diffusion induced modulation of co-propagating (acousto-optic) waves has been investigated in transversely magnetized semiconductor plasmas, viz. n-InSb at 77 K. Using coupled mode theory, the role of diffusion of carriers on the threshold field and gain profile of the modulated wave has been investigated. The origin of the AO interaction is assumed to lie in the induced nonlinear diffusion current density of the medium. An expression for effective third-order susceptibility describing the phenomena has been obtained. The threshold pump field and the steady state growth rates are determined from the effective third-order polarization in the medium. The presence of an external static transverse magnetic field is found to be favourable for the onset of diffusion induced modulation amplification of the modulated wave in heavily doped regime. Analytical investigation reveals that in the presence of enhanced diffusion due to excess charge carriers the modulated beam can be effectively amplified in a dispersion-less acoustic wave regime.

Keywords

Nonlinear phenomena, wave interactions, mode coupling, acousto-optical effects, photo acoustic effects, optical susceptibility, III-V semiconductors.

INTRODUCTION

The interaction of pulsed laser beams with semiconductor plasma has been playing an important role in diverse areas of scientific research for several decades [1-3]. It has numerous applications in processing of materials and fabrication of devices [4, 5]. Semiconductors also provide a compact and less expensive medium to model nonlinear phenomena encountered in laser induced plasmas. There exist a number of nonlinear interactions which can be classified as modulation interaction. The resulting amplification of decay channels by modulation interactions are generally referred to as an instability of wave propagating in nonlinear dispersive medium such that the steady state becomes unstable and evolves into a temporally modulated state.

The concept of transverse modulation instability originates from a space-time analogy that exists when the dispersion is replaced by diffraction [6]. The field induced change in the refractive index due to a change in the local optical characteristics of semiconducting medium leads to modulation instability, nonlinear focusing, or filamentation of propagating beams. Moreover, electro-optic and acousto-optic (AO) effects afford a convenient and widely used means of controlling intensity and/or phase of the propagating radiation [7]. This modulation is used in ever-expanding number of applications including the impression of information onto optical pulses, mode-locking, and optical beam deflection [8]. The modulation of electromagnetic beams by surface-acoustic waves is also a very active field of research due to their applicability in the field of communication devices [9].

It is known that the acoustic wave (AW) diffracts the light beam within the active medium and provides an effective mechanism for nonlinear optical response in AO devices. Specifically, the photo elastic effect in a medium causes a variation in the medium's refractive index which is proportional to an acoustic perturbation

and implies the existence of a corresponding electrostrictive effect. It induces an acoustic response in the medium that is a spatially varying quadratic function of the local electric field. AO interaction in semiconductors is playing an important role in optical modulation and beam steering [10, 11]. However, in integrated optoelectronic device application, the AO modulation process becomes a serious limitation due to high acoustic power requirements. The most direct approach to this problem is to tailor new materials with more desirable AO properties.

In most cases of investigation of nonlinear optical interaction, the nonlocal effects such as diffusion of the excitation carrier density that is expected to be responsible for the nonlinear refractive index change has been ignored. It is found that increased diffusion makes light transmission more difficult and tends to wash out the local equilibrium of the equivalent potential representing unstable or stable TE nonlinear surface waves [12]. The high mobility charge carriers makes diffusion effects even more relevant in semiconductor technology as they (charge carriers) travel significant distances before recombining. Therefore inclusion of carrier diffusion in theoretical studies of nonlinear wave interactions seems to be very important from the fundamental as well as application view points and thus attracted many workers in the last decades [13-14]. The diffusion is expected to alter the third-order optical susceptibility $\chi^{(3)}$ and hence significantly changes dispersion and transmission of the incident radiation in the medium [14]. However, it appears from the available literature that no attempt has so far been made on the important role of diffusion on frequency modulation and related phenomena in semiconductor plasmas.

In the present paper we have presented an analytical study on diffusion induced modulation of co-propagating waves in an electrostrictive semiconductor plasma in the presence of excess charge carriers. The effect of diffusion-induced current density on the nonlinear interactions of a laser beam adds new dimensions to the analysis presented in an *n*-type semiconductor. The intense pump beam generates an AW within the semiconductor medium that induces an interaction between the free carriers through electron plasma wave and the acoustic phonons through material vibrations. This interaction induces a strong space-charge field that modulates the pump beam. Thus the optical and AWs present in an acousto-optic modulator can be strongly amplified through nonlinear optical pumping. The analysis is based on coupled mode theory for investigating the modulation instability due to parametric four-wave mixing process. The acousto-optic field couples with the modulated signal in the presence of a strain and amplifies it under appropriate phase-matching conditions. The parametric process is characterized by the effective third-order optical susceptibility induced due to diffusion current density in a centrosymmetric semiconductor plasma medium. The effective AO (third order) susceptibility describing the four wave interaction has been deduced from single-component fluid model of plasma and Maxwell's equations. A linear stability analysis of the growth rate of the modulated signal is presented. The threshold pump intensity required to incite the transverse modulation amplification has also been derived. The numerical estimates are made of the threshold intensity and gain of the modulated signal wave and their dependence on the external parameters.

THEORETICAL FORMULATIONS

An active AO semiconductor crystal is considered to be illuminated by a uniform and homogeneous optical pump beam

$$\vec{E}_0 = \hat{x}E_0 \exp(-i\omega_0 t) \quad (1)$$

which co-propagates with a parametrically generated AW within the medium. The medium is immersed in a transverse static magnetic field $\vec{B}_0 = \hat{z}B_0$. Due to medium's photo-elastic response, these acoustic grating results in a proportional refractive index variation. The incident optical field will be diffracted by this grating to produce an additional field within the medium. The diffracted beam is either frequency up-shifted (anti-stokes mode) or down shifted (stokes mode) depending on the orientation of the incident wave. In the presence of strain stokes and anti-stokes mode can be coupled over a long interaction path. This coupled wave propagates as a solitary wave form in the dispersion-less regime of the AW and can be amplified under appropriate phase matching conditions. In equation (1), under the dipole approximation the incident pump

beam is assumed to be spatially uniform when the excited wave have wavelengths which one very small as compared to the scale length of the pump field variation (*i.e.*, $\vec{k}_0 \ll \vec{k}$ so that \vec{k}_0 may be safely neglected).

The basic equations governing the modulation interactions are:

$$\frac{\partial \vec{v}_0}{\partial t} + \nu \vec{v}_0 = \frac{e}{m} (\vec{E}_0 + \vec{v}_0 \times \vec{B}_0) = \frac{e}{m} \vec{E}_{eff} \tag{2}$$

$$\frac{\partial \vec{v}_1}{\partial t} + \nu \vec{v}_1 + \left(\vec{v}_0 \cdot \frac{\partial}{\partial x} \right) \vec{v}_1 = \frac{e}{m} (\vec{E}_1 + \vec{v}_1 \times \vec{B}_0) \tag{3}$$

$$\frac{\partial n_1}{\partial t} + n_0 \frac{\partial v_1}{\partial x} + v_0 \frac{\partial n_1}{\partial x} - D \frac{\partial^2 n_1}{\partial x^2} = 0 \tag{4}$$

in which diffusion coefficient

$$D = \frac{k_B T}{e} \mu \tag{5}$$

The subscripts 0 and 1 correspond to the physical quantities related to pump and signal modes, respectively. Equations (2) and (3) are the momentum transfer equations for the pump and the product waves, respectively in which \vec{v}_0 and \vec{v}_1 are the oscillatory fluid velocities under the influence of the respective fields. ν and m represent the phenomenological momentum transfer collision frequency and effective mass of electrons. Under the assumption $\omega_p \sim \omega_0$ the contribution of pump magnetic field is neglected. Equation (3) represents the continuity equation in which n_0 and n_1 are the equilibrium and the perturbed carrier concentrations, respectively. In equation (5) $\mu (= e/m\nu)$ is the electron mobility k_B is the Boltzmann's constant and T the temperature in K. The basic nonlinearity induced in the motion of the charge carriers is due to the convective derivative $(\vec{v} \cdot \vec{\nabla})\vec{v}$ and Lorentz force $e(\vec{v} \times \vec{B})$ which are the functions of the total intensity of illumination $\vec{v}_{0,1}$.

In the multimode theory of modulation interaction the pump beam generates an acoustic perturbation due to the lattice vibrations at the phonon mode frequencies within the semiconductor. These lattice vibrations lead to an electron-density perturbation which couples nonlinearly with the pump wave and drives the AWs at modulated frequencies. The equation of motion of the AW in a centrosymmetric electrostrictive medium is given by

$$\frac{\partial^2 u}{\partial t^2} - \frac{C}{\rho} \frac{\partial^2 u}{\partial x^2} + 2\Gamma_a \frac{\partial u}{\partial t} = \frac{1}{2\rho} \varepsilon (\eta^2 - 1) \frac{\partial}{\partial x} (\vec{E}_{eff} \cdot \vec{E}_1^*) \tag{6}$$

where u is the lattice displacement under the influence of the interfering electromagnetic fields represented by the generalized force on the right hand side of equation (6), ρ is the mass density of the crystal, C the elastic constant, η the linear refractive index, Γ_a the damping constant and ε the permittivity of the crystal.

The acoustic field thus generated is also assumed to have a plane wave variation $\exp[i(k_a x - \omega_a t)]$.

The migration of charge carriers via diffusion produces a charge separation that leads to a strong space-charge field. This space-charge can thus be obtained from the continuity equation [Eq. (4)] and the Poisson's equation for superposition of Coulomb fields arising from the excess charge density n_1 and free or equilibrium density n_0 [Eq. (7)], as

$$\frac{\partial \vec{E}_1}{\partial x} = \frac{n_1 e}{\varepsilon} + \frac{(\eta^2 - 1)}{\varepsilon_1} \vec{E}_{eff} \frac{\partial^2 u}{\partial x^2} \tag{7}$$

The induced current density $J(x,t)$ is assumed to consist of drift and diffusion terms near thermal equilibrium at 77 K whose x -component may be represented in the form

$$J(x,t) = e\mu nE - eD \frac{\partial n}{\partial x} \tag{8}$$

The carrier density perturbation induced by the strong pump beam is associated with the phonon-mode and varies at the acoustic frequency. The pump beam is thus phase modulated by the density perturbations to produced enforced disturbances at the upper $(\omega_a + \omega_0)$ and lower $(\omega_a - \omega_0)$ side band frequencies. The higher order frequency components are filtered out by assuming a long interaction path. The modulation process under consideration must also fulfill the phase matching conditions $\hbar k_0 \approx \hbar k_1 \pm \hbar k_a$ and $\hbar \omega_0 \approx \hbar \omega_1 \pm \hbar \omega_a$ under spatially uniform laser irradiation. The equation for carrier density fluctuation of the coupled electron-plasma wave in a magnetized n -type semiconductor, is obtained by employing equations (1–8) and the linearized perturbation theory as:

$$\frac{\partial^2 n_1(\omega_{\pm}, k_{\pm})}{\partial t^2} + v \frac{\partial n_1(\omega_{\pm}, k_{\pm})}{\partial t} + \bar{\omega}_p^2 n_1(\omega_{\pm}, k_{\pm}) - vD \frac{\partial^2 n_1(\omega_{\pm}, k_{\pm})}{\partial x^2} - \frac{n_0 e k_a^2 (\eta^2 - 1)}{m \epsilon_1} E_{eff} u^* = -\frac{e}{m} E_{eff} \frac{\partial n_1(\omega_{\pm}, k_{\pm})}{\partial x} \tag{9}$$

in which $\bar{\omega}_p^2 = \omega_p^2 \left(1 + \frac{\omega_c^2}{v^2}\right)^{-1}$. Here $\omega_p^2 = \frac{n_0 e^2}{m \epsilon}$ is the plasma frequency and $\omega_c = \frac{e B_0}{m}$ is the cyclotron frequency of the carriers. The corresponding density modulation oscillating at the upper and lower side band frequencies can be represent by the expression

$$n_1(\omega_{\pm}, k_{\pm}) = \frac{n_0 e k_a^2 (\eta^2 - 1) E_{eff} u^*}{m \epsilon_1} \left[\bar{\omega}_p^2 + vD k_{\pm}^2 - \omega_{\pm}^2 - iv \omega_{\pm} + ik_{\pm} (e/m) E_{eff} \right]^{-1} \tag{10}$$

where

$$u^* = \frac{-ik_a \epsilon (\eta^2 - 1) E_{eff}^* E_1}{2\rho(\omega_a^2 - k_a^2 v_a^2 - 2i\Gamma_a \omega_a)} \tag{11}$$

is obtained from equation (6) substitution of equation (11) in (10) yields,

$$n_1(\omega_{\pm}, k_{\pm}) = \frac{-in_0 \epsilon_0 e k_a^2 (\eta^2 - 1)^2 |E_{eff}^*|^2 E_1}{2\rho m (\omega_a^2 - k_a^2 v_a^2 - 2i\Gamma_a \omega_a)} \times \left[\bar{\omega}_p^2 + vD k_{\pm}^2 - \omega_{\pm}^2 - iv \omega_{\pm} + ik_{\pm} (e/m) E_{eff} \right]^{-1} \tag{12}$$

The density perturbation oscillating at the forced frequency in equation (12) are obtained under the quasi-static approximation and by neglecting the Doppler shift due to travelling space-charge waves. We also neglect the contribution of transition dipole moment in the analysis of modulation instability to study the effect of nonlinear current density due to diffusion of the charge carriers only. The diffusion-induced nonlinear current densities for the upper and lower side-bands may be expressed as

$$J_1(\omega_+, k_+) = -eD \frac{\partial n_1(\omega_+, k_+)}{\partial x} \tag{13a}$$

$$J_1(\omega_-, k_-) = -eD \frac{\partial n_1(\omega_-, k_-)}{\partial x} \tag{13b}$$

In a centrosymmetric medium, the four-wave parametric interaction involving the incident pump, the upper and lower side-band signals and the induced acousto-optic idler wave characterized by the cubic nonlinear



susceptibility tensor effectively results in modulation instability of the pump. The cubic nonlinear optical polarization at the modulated frequencies is defined as

$$P_{eff} = \epsilon_0 \chi_d^{(3)} E_0(\omega_0, k_0) E_1(\omega_+, k_+) E_1(\omega_-, k_-) \tag{14}$$

The induced polarization P_d is treated as time integral of the nonlinear current density $J_1(\omega_{\pm}, k_{\pm})$. The effective polarization has contributions from both the individual side bands and can be represented as

$$P_{eff}(\omega_{\pm}, k_{\pm}) = P_d(\omega_+, k_+) + P_d(\omega_-, k_-) \tag{15}$$

Thus the effective nonlinear susceptibility of the electrostrictive medium induced by the carrier diffusion in a four-wave mixing process can be obtained using equations (12–15) as

$$\chi_d^{(3)} = \frac{-2iDvn_0 e^2 k_a^4 (\eta^2 - 1)^2}{2\rho m (\omega_a^2 - k_a^2 v_a^2 - 2i\Gamma_a \omega_a) (\omega_0^2 - \omega_c^2)^2} \times \left[\left(\delta^2 + v^2 - \frac{k^2 (e/m)^2}{\omega_0^2} E_{eff}^2 \right) + \frac{2ik(e/m)\delta}{\omega_0} E_{eff} \right]^{-1} \tag{16}$$

in which $\delta = \bar{\omega}_p^2 - \omega_0 + \frac{vDk^2}{\omega_0}$.

The effective nonlinear susceptibility [Eq. (16)] may be termed as diffusion induced third-order susceptibility of the crystal. It characterizes the steady-state optical response of the medium and governs the nonlinear wave propagation through the medium due to diffusion of the charge carrier in presence of a transverse static magnetic field. Hence the process may be termed as diffusion-induced modulation interaction. For non-dispersive acoustic mode *i.e.* for $\omega_a = k_a v_a$, rationalization of equation (16) yields

$$\left[\chi_d^{(3)} \right]_r = \frac{Dvn_0 e^2 k_a^4 \omega_0 (\eta^2 - 1)^2}{\rho m \Gamma_a \omega_a (\omega_0^2 - \omega_c^2)^2} \times \frac{k\delta(e/m)E_{eff}}{\left[\left(\delta^2 + v^2 - \frac{k^2 (e/m)^2}{\omega_0^2} E_{eff}^2 \right)^2 + \frac{4k^2 (e/m)^2 \delta^2}{\omega_0^2} E_{eff}^2 \right]} \tag{17a}$$

$$\left[\chi_d^{(3)} \right]_i = \frac{Dvn_0 e^2 k_a^4 \omega_0 (\eta^2 - 1)^2}{\rho m \Gamma_a \omega_a (\omega_0^2 - \omega_c^2)^2} \times \frac{\left(\delta^2 + v^2 - \frac{k^2 (e/m)^2}{\omega_0^2} E_{eff}^2 \right)}{\left[\left(\delta^2 + v^2 - \frac{k^2 (e/m)^2}{\omega_0^2} E_{eff}^2 \right)^2 + \frac{4k^2 (e/m)^2 \delta^2}{\omega_0^2} E_{eff}^2 \right]} \tag{17b}$$

Equation (17) can be employed to obtain the steady state gain via $\left[\chi_d^{(3)} \right]_i$ as well as the dispersive characteristics via $\left[\chi_d^{(3)} \right]_r$ of the modulated waves. It can be observed from equation (17a) that there is an intensity dependent refractive index leading to the possibility of a focusing or defocusing effect of the propagating beam. Equation (17a) reveals the negative dispersive characteristics of the dissipative medium at $\omega_c > \omega_0$. As $\left[\chi_d^{(3)} \right]_i$ becomes negative one may expect more effective self focusing of the modulated signal for normal dispersion characteristics. Hence the application of magnetic field adds new dimensions to this interaction process. However we cannot increase the value of magnetic field indefinitely as with $\omega_c \gg \omega_0$, cyclotron absorption phenomenon may dominate the instability process.

In order to explore the possibility of diffusion-induced modulation amplification in a centrosymmetric semiconductor, we employ the relation

$$\alpha_e = \frac{k}{2\varepsilon_1} [\chi_d^{(3)}]_i |E_0|^2 \tag{18}$$

where α_e is the nonlinear absorption coefficient. The nonlinear steady state growth of the modulated signal is possible only if α_e , obtainable from equation (18), is negative. Thus from equations (17b, 18) we can infer that in the present case, in order to attain a growth of the modulated signal, $[\chi_d^{(3)}]_i$ should be negative. Thus the condition for achieving a positive growth rate is as follows:

$$k^2 (e/m)^2 E_{eff}^2 > \omega_0^2 (\delta^2 + v^2). \tag{19}$$

Thus it is evident from above discussion that not only the presence of particle diffusion in an externally imposed magnetic field is an absolute necessity to induce instability but also the value of applied pump intensity must be greater than the threshold value. In order to determine the threshold value of the pump amplitude required for the onset of the modulation amplification, we set $k^2 (e/m)^2 E_{eff}^2 = \omega_0^2 (\delta^2 + v^2)$ and obtain

$$E_{0th} = \frac{m}{ek} \sqrt{(\delta^2 + v^2)} \frac{(\omega_0^2 - \omega_c^2)^2}{\omega_0}. \tag{20}$$

It can be observed from equation (20) that the transverse modulation instability of the signal wave has a non-zero intensity threshold, even in the absence of collision damping. The threshold field E_{0th} is found to have complex characteristics and is strongly dependent on the externally applied magnetic field. A detailed investigation about the nature of the steady state gain factor reveals that an appreciable amplification of the modulated signal ($g = -\alpha_e$) is obtainable only under the condition of non-dispersion *i.e.* as $\omega_a \rightarrow k_a v_a$. The above formulation reveals that the presence of a magnetic field enhances the growth rate of the modulated signal. It is found that the growth rate of the signal is independent of its frequency and instead, it depends on the frequency of the pump and that of the acoustic-wave; a fact in agreement with the experimental results [15]. It is also found to be influenced by the carrier concentration n_0 .

RESULTS AND DISCUSSION

The diffusion induced modulation amplification of the co-propagating waves in the electrostrictive Kerr medium is due to the linear dispersion effects in combination with the nonlinear processes. The amplification of the modulated electromagnetic wave is critically dependent on the coupling of the electron-plasma wave and the generated AW. Thus the amplification process can be controlled by the carrier density of the medium that governs the effective plasma frequency in the presence of the intense pump beam and the diffusion of charge carrier in the medium. The amplification is expected to be higher in the presence of a strong electron plasma wave that enhances the coupling between interacting waves. The amplification of the modulated wave is maximum for the most efficient coupling of the side band signal. Thus any process that reduces the phase mismatch will consequently enhance the modulation amplification process. The presence of strong AW in the system as an “idler” serves as an effective mean to reduce the phase mismatch between interacting waves.

An externally generated AW can also be subjected into the system to enhance the modulation amplification process as it would improve the grating strength. The presence of an external AW is found to add coherently to the induced AW in case of a Bragg diffracted single side band Stokes component (Eq. (11)). However, this additional sound wave will modify the Stokes–anti-Stokes coupling parameter and the space-charge field also needs to be adjusted to be accounted for in the present theory.

The analytical investigations for the possibility of transverse modulation instability and the consequent amplification of modulated waves resulting from the transfer of modulation from the pump wave to the modulated wave are dealt with in the preceding section. The analytical results obtained are applied to a

centrosymmetric *n*-type III-V semiconductor viz. n-InSb being irradiated by 10.6 μm pulsed CO₂ laser at 77 K. The physical parameters considered for the analysis are:

$$m = 0.0145m_0, \quad \rho = 5.8 \times 10^3 \text{ kgm}^{-3}, \quad v = 3 \times 10^{11} \text{ s}^{-1}, \quad \epsilon_1 = 15.8, \quad \eta = 3.9, \quad n_0 = 10^{24} \text{ m}^{-3}, \quad \omega_a = 10^{12} \text{ s}^{-1}, \\ v_a = 4 \times 10^3 \text{ ms}^{-1}, \quad \omega_0 = 1.78 \times 10^{14} \text{ s}^{-1}, \quad \Gamma_a = 2 \times 10^{10} \text{ s}^{-1}, \quad \omega_c = 10^{12} \text{ s}^{-1}.$$

The numerical estimations dealing with the external parameters influencing the threshold field required for the onset of modulation amplification process are plotted in Figures 1 and 2.

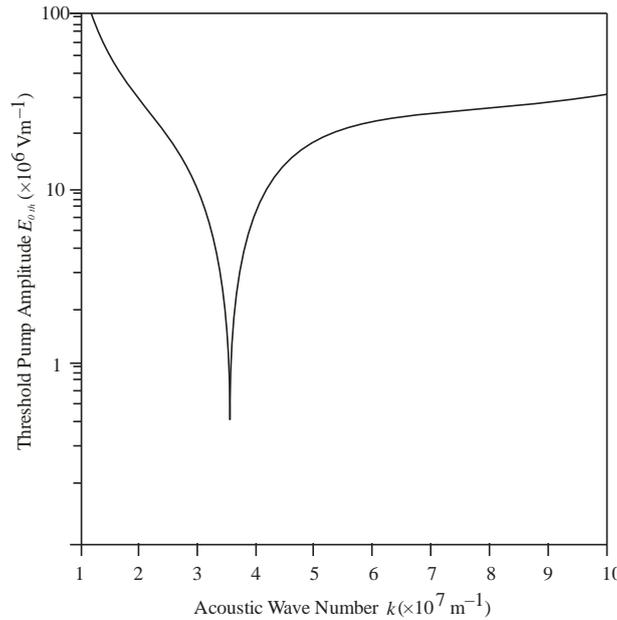


Fig. 1. Dependence of threshold pump amplitude E_{0th} on AW number k for $n_0 = 10^{24} \text{ m}^{-3}$, $v_a = 4 \times 10^3 \text{ ms}^{-1}$, $\omega_0 = 1.78 \times 10^{14} \text{ s}^{-1}$, $\omega_c = 0.01 \omega_0$.

It can be observed from Figure 1 that for smaller magnitudes of k_a (such that $\omega_0(\bar{\omega}_p - \omega_0)/vD \gg k_a^2$), E_{0th} decreases with k_a as k_a^{-1} , and at $\omega_0(\bar{\omega}_p - \omega_0)/vD \approx k_a^2$, E_{0th} is found to be minimum and further when $\omega_0(\bar{\omega}_p - \omega_0)/vD < k_a^2$ then E_{0th} shows a steep increment.

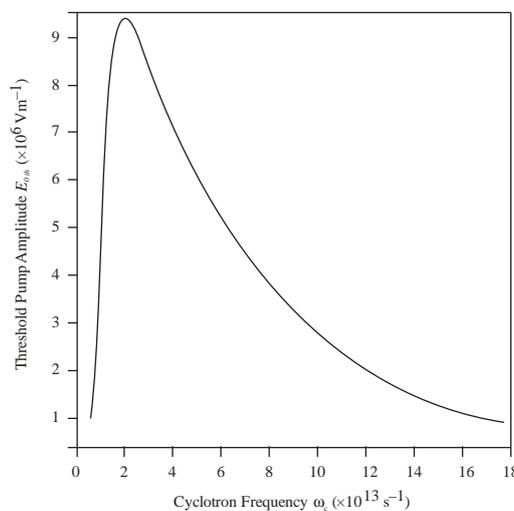


Fig. 2. Dependence of threshold pump amplitude E_{0th} on magnetic field via cyclotron frequency ω_c for the parameters as in Figure 1, when $k = 2.5 \times 10^8 \text{ m}^{-1}$.

Figure 2 shows the dependence of E_{0th} on the external dc magnetic field B_0 (in terms of cyclotron frequency ω_c). It is found that the threshold field required for inciting the modulation amplification is much less at lower value of magnetic field. E_{0th} is found to increase till the magnetic field approaches 1 T (corresponding to a cyclotron frequency nearly equal $1.78 \times 10^{13} \text{ s}^{-1}$). However for $\omega_c > 2 \times 10^{13} \text{ s}^{-1}$ one encounters a drop in the value of the required threshold field at $k_a = 2.5 \times 10^8 \text{ m}^{-1}$. The occurrence of this maxima may be attributed to the dependence of E_{0th} on a factor $f(\omega_c) = (\delta^2 + v^2)^{1/2} (\omega_0^2 - \omega_c^2)$ as evident from equation (20). Thus the presence an external transverse dc magnetic field for which $\omega_c > 2 \times 10^{13} \text{ s}^{-1}$, effectively reduces the threshold field. This behaviour may be attributed to the presence of effective Hall field induced by applied transverse dc magnetic field corresponding to cyclotron frequency more than $2 \times 10^{13} \text{ s}^{-1}$.

Figure 3 depicts the variation of the modulated growth rate g with respect to wave number k . The gain constant g has the usual $g \propto [ak^2(b|E_0|^2 - ak^2)]^{1/2}$ dependence on k characterizing a parametric four-wave coupling process [16]. This results in the gain of the modulationally unstable propagating signal g increases initially with k and attains a maximum around $\omega_a \approx kv_a$, i.e. the non-dispersive acoustic mode. However, in the negative group velocity regime (when $\omega_a < kv_a$); g drops sharply due to the focusing of the beam as evidenced by the positive dispersive characteristics of the AO susceptibility tensor [Eq. (16)].

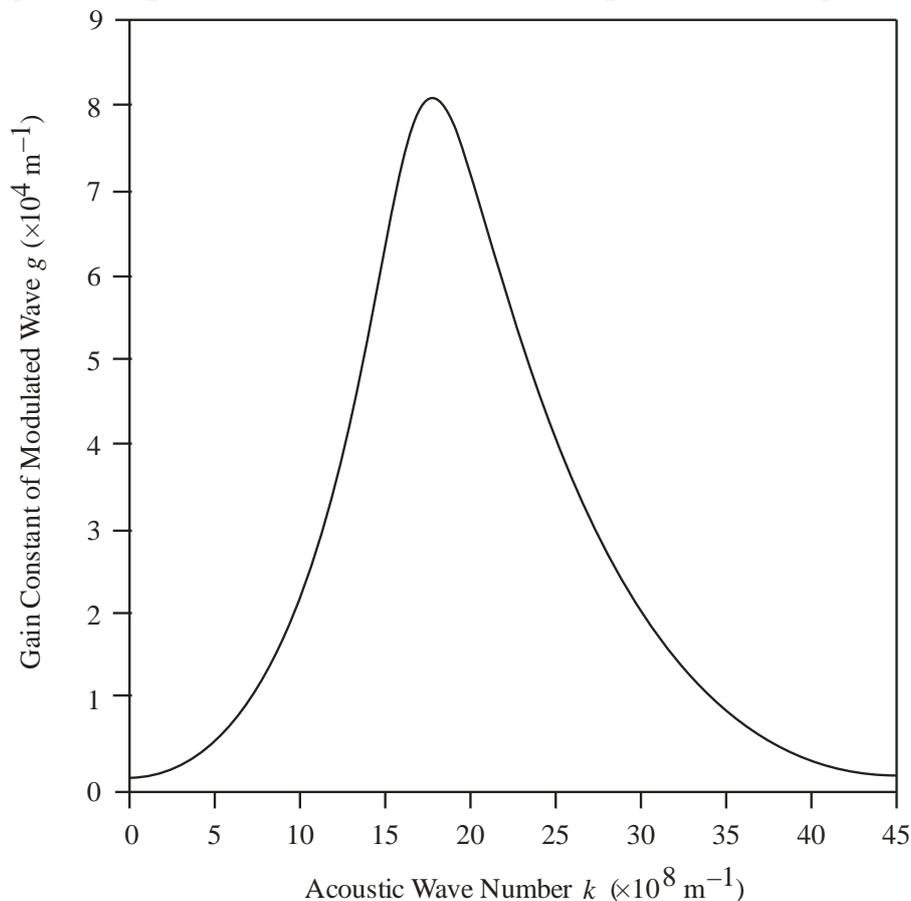


Fig. 3. Dependence of gain constant of modulated wave on wave number k when $\epsilon = 0.001$.

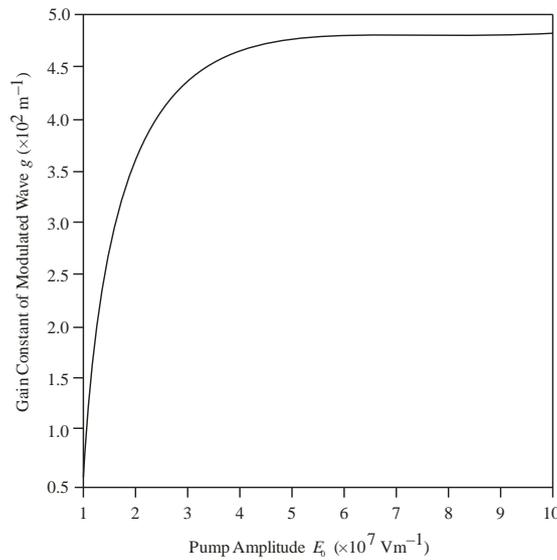


Fig. 4. Variation of gain constant of modulated wave with pump field E_0 for the parameters as in Figure 1. Here $k = 2.5 \times 10^8 \text{ m}^{-1}$.

Figures 4 to 6 display the numerical estimations of equation (18) at electric fields higher than the threshold value. These estimations are plotted for a non-dispersive acoustic mode with $\omega_a \approx kv_a$ (*i.e.* with $k_a = 2.5 \times 10^8 \text{ m}^{-1}$, $v_a = 4 \times 10^3 \text{ ms}^{-1}$ and $\omega_a = 10^{12} \text{ s}^{-1}$) in the heavily doped regime ($n_0 = 10^{24} \text{ m}^{-3}$) g increases with E_0 after overcoming the attenuation below the threshold field and exhibits a nearly independent behaviour due to modulation of effective acousto-optic modulation susceptibility which is induced by the space-charge field. Here g is now independent of applied electric field as the diffusive forces are balanced by the enhanced dielectric relaxation frequency $\bar{\omega}_R$ and electron plasma frequency ω_p . In the heavily doped regime due to the enhanced plasma frequency $\omega_p \rightarrow \omega_0$ the density of the space-charge wave is also increased resulting in a reverse transfer of energy from the acousto-optic field to the material waves in the resonant regime resulting in an attenuation of modulated wave. However, as the pump field increases further, it becomes strong enough to derive the space-charge wave overcoming dragging effects due to the diffusive forces and therefore exhibits an exponential growth.

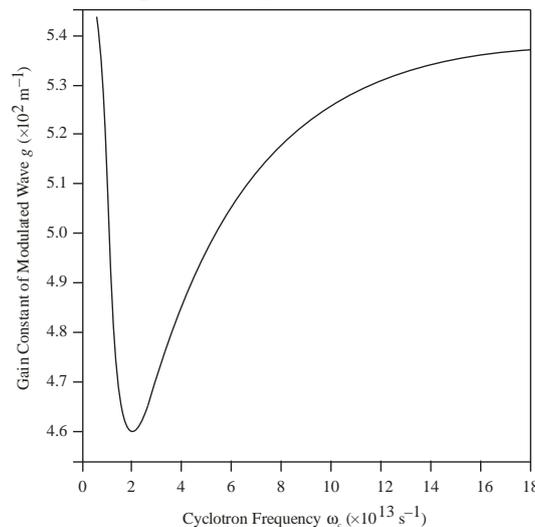


Fig. 5. Variation of gain constant of modulated wave on magnetic field via cyclotron frequency ω_c for the parameters as in Figures 1 and 2.

The variation of the growth rate with dc magnetic field B_0 (in terms of ω_c) has been depicted in Figure 5 taking k as a parameter. It is found from this curve that g decreases sharply with the increase in ω_c and attains a minimum value at $\omega_c \approx v$. In this part of the curve the magnetic field has been trying to overcome the frictional losses and as soon as it overcomes ($\omega_c > v$) the frictional losses due to increase in the Hall drift energy the gain increases with the increase in the applied dc magnetic field. But we cannot increase the value of ω_c indefinitely because after a certain value cyclotron absorption becomes important and one has to restructure the present theory accordingly.

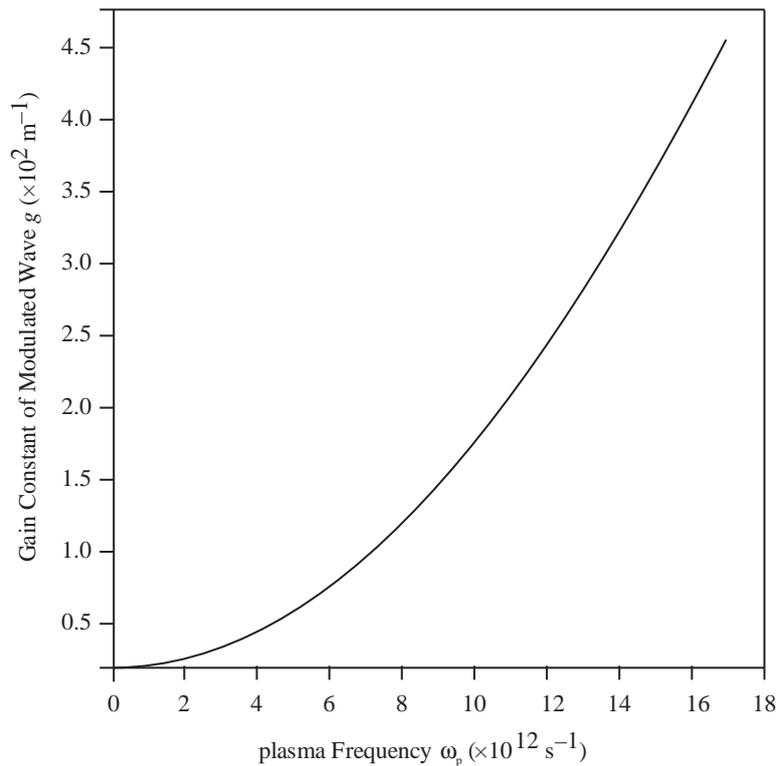


Fig. 6. Variation of gain constant of AW with carrier concentration via n_p for the parameters as in Figures 1 and 2.

In Fig. 6 we have plotted the growth rate of the signal as a function of electron density n_0 , for a dispersionless regime of the low frequency acoustic mode. It is found that the growth rate of the transversely modulated wave increases with a rise in electron density of the medium. The nature of the curve is similar to the conclusion arrived at by Salimullah and Singh [17] who considered the modulational interaction of an extraordinary mode subjected to perturbation parallel to magnetic field. Hence higher amplification of the waves can be attained by increasing the carrier concentration of the medium by n -type doping in the crystal. However, the doping should not exceeds the limit for which the plasma frequency ω_p exceeds the input pump frequency ω_0 , because in the regime where $\omega_p > \omega_0$ the electromagnetic pump wave will be reflected back by the intervening medium. It may be thereby concluded that heavily doped semiconductors are the most appropriate hosts for diffusion-induced modulation instability processes.

The preceding analysis has been performed for III-V semiconductors like n -type InSb with electron density approaching critical density (*i.e.* carrier densities for which the corresponding electron plasma frequency is

comparable to the incident pump frequency $\omega_0 \approx \omega_p$). Carrier densities of such high magnitudes are quite relevant to semiconductors of the III-V group and have been extensively employed by several workers to study the various characteristics [18].

The above discussion thereby provides an insight into developing potentially useful diffusion-induced acousto-optical modulators by incorporating the material characteristics of the medium.

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The acousto-optic modulation is the convenient and widely used means of controlling intensity and/or phase of propagating radiation [1, 2]. The conventional way of controlling phonons takes advantage of size confinement. These are used to tailor the propagation properties of acoustic and optical phonons, as well as their interactions with optical fields. The concept of transverse modulational instability originates from a space-time analogy that exists when the dispersion is replaced by diffraction and instability of a plane wave in self focusing Kerr medium. A large number of attempts have be